

Réseau national de la métrologie française

LNE: Laboratoire national de métrologie et d'essais
- *Institut LNE-Nanotech*

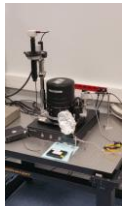
LNE-LNHB: Laboratoire national Henri Becquerel



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LNE

GDR NAME – 9 mai 2021

Thermal



SThM



Frequency
domain PTR

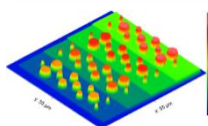
Electrical



SMM in controlled env.



C-AFM



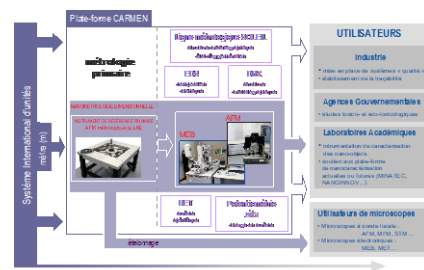
Cal. kits



Evaluation of metrological
performances of new
instruments / sensors



Characterisation of materials
properties at the nm scale
(thermal, electrical, ...)



Development of tools and methods to
allow implementation of national or
European regulations on
nanomaterials



Characterization of
nanomaterials in complex
medias (consumer product,
water, biological media...)

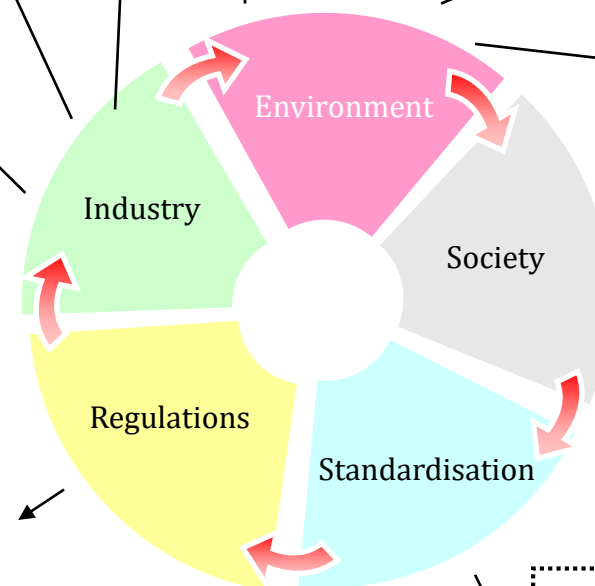


Aerosols characterisation
(generation, air pollution,
occupational risk...)



Characterisation of health
and environmental risks of
manufactured
nanomaterials

→ Dustiness, Wear, Migration
from packaging material, End-
of-life (combustion / waste
incineration)



Measurement protocols
transfer towards
standardisation bodies

Combined X-ray analysis by X-Ray Reflectivity (XRR) and Grazing Incidence X-Ray Fluorescence (GIXRF)

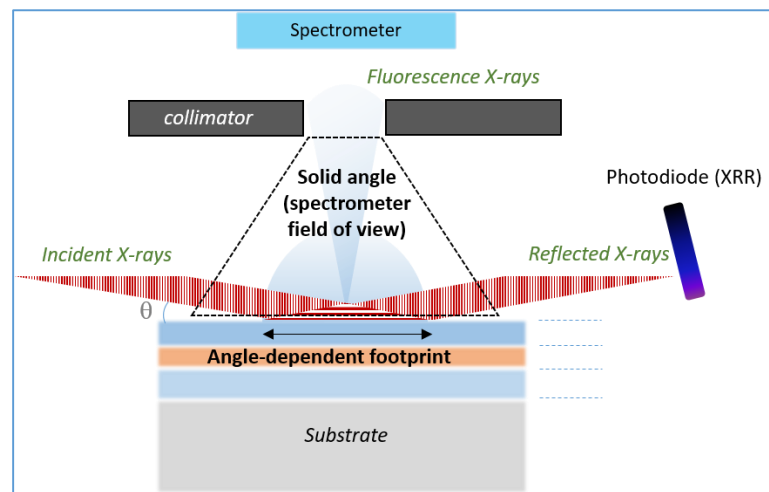
Non-destructive technique to control the precision of **thin film deposition** by giving access to the parameters of the different layers (**thickness, roughness, composition, density, depth profile**).

Measurement principle:

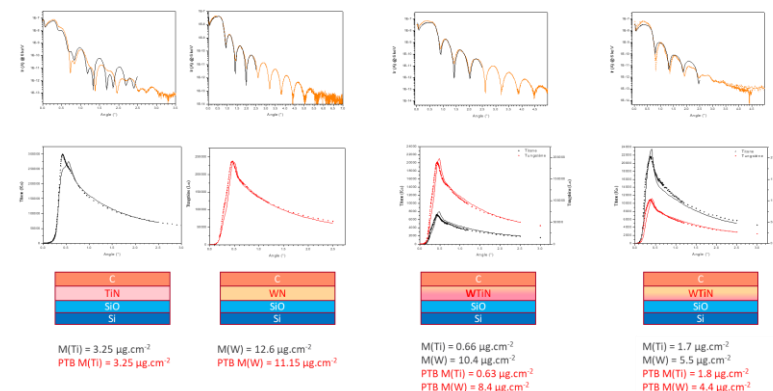
- Monochromatic X-rays grazing the sample surface,
- Rotation of the sample (small angles),
- The incident beam progressively penetrates the sample and allows the analysis of its depth structure.

Experimental set-up:

Use of synchrotron radiation (**SOLEIL**)
with a specific goniometer (**CASTOR**).



Characterization of layers with thicknesses of a few nm



The LNHB develops its own software for data acquisition, XRF spectra processing and multilayer modeling.
The use of both techniques allows to obtain complementary information and to remove ambiguities.
The reference-free approach uses only fundamental atomic parameters to characterize the multilayer:
No need of reference standard.

Merci de votre attention !